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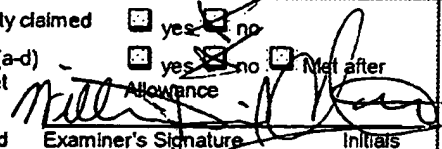
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\*\* CONTINUING DATA \*\*\*\*\* NONE 

\*\* FOREIGN APPLICATIONS \*\*\*\*\* NONE 

IF REQUIRED, FOREIGN FILING LICENSE  
GRANTED

\*\* 03/10/2004

Foreign Priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no	STATE OR COUNTRY CA	SHEETS DRAWING 5	TOTAL CLAIMS 20	INDEPENDENT CLAIMS 3
35 USC 119 (a-d) conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no <input type="checkbox"/> Met after Allowance				
Verified and Acknowledged  Examiner's Signature	Initials			

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## TITLE

Process for fabrication of spacer layer with reduced hydrogen content in semiconductor device

FILING FEE	FEES: Authority has been given in Paper	<input type="checkbox"/> All Fees
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